#### THOMSON SCIENTIFIC



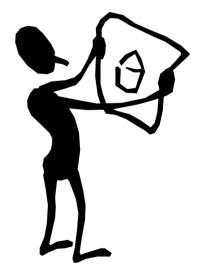
# Derwent World Patents Index (DWPI) - process outline

Doina Nanu June 2007



#### What is a Patent?

- Legal contract
  - inventor (assignee) and government
  - Right to stop others from making, using or selling the invention
    - for a limited period (usually 20 years)
- When granted can be bought, sold, hired or rented
- A complete disclosure of the invention





### How do you get a patent?

- 1: Invent something
  - incremental improvement
- 2: Draft application
  - Patent agent/attorney
- 3: File at Patent Office
  - Filing Date
  - Application number
- 4: First examination and publication
- 5: Detailed examination and publication
- 6: Grant, lapse, expiry or withdrawal

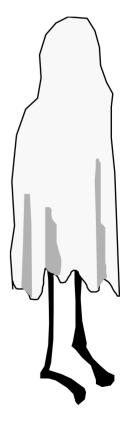




## **Hiding the invention**

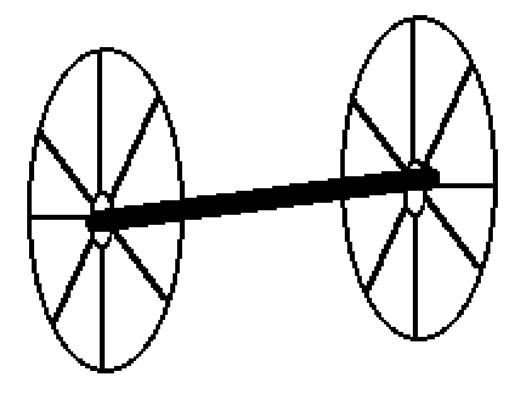
#### • Engineering - "Patentese"

A device comprises inner and outer concentric annular elements linked by a plurality of elongate members radiating from the outer circumferential surface of said inner annulus to the inner circumferential surface of said outer annulus, an opening being provided in the centre of said inner annulus for receiving the end of an elongate member, the other end of said elongate member being inserted into an identical device.





#### What does all that mean?



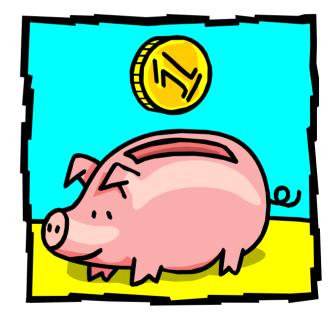


# Keeping the wolves away

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#### **Why Use Patent Information?**

- Avoid wasteful duplication of R&D effort
  - Novelty and Prior Art Searching
  - State of the art
- Identification of research fronts
  - Expert in the field
- Infringement and opposition
- Monitoring competitors
- Solutions to technical problems
- Licensing opportunities





#### **Who Uses Patent Information ?**

- Strategic Planners
  - Business Analysts
  - Marketing Professionals
- Information Professionals

- Patent Attorneys
- Research Scientists
- Design Engineers
- R&D Managers





#### **The Information Challenge**

- Over two million patents are issued world wide per annum
  - ~38,000 processed weekly for DWPI
- Unique information, about 80% not published elsewhere<sup>1</sup>
- Information held within a patent is a vital source of information for:
  - Research and Development
  - Competitive Intelligence

<sup>1</sup>(source: European Patent Office)





#### **Complexity of the patenting system**

- The same invention can be protected as a patent in many countries through:
  - national route (filing the invention with the respective national patent office)
  - International route (by using the PCT- Patent Convention Treaty system administered by WIPO)
  - Regional route (by using the EPC European Patent convention- system administered by the EPO; )
- Can have multiple applications in the same country (divisions, continuations, continuations-in-part etc.)
- Translations into local languages from international or regional applications (e.g. European Patent Office, or World Intellectual Property Organisation)



## What is "Priority"?

- Paris Convention (1883) regulates the priority system
- File first application
  - Receive filing date (Priority)
- File in other countries

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- within 12 months (+2)
- Further applications benefit of legal protection from the filing date of first application
- The earliest <u>publication</u> that brings the invention into the public domain is *usually 18 months* from the priority filing





## The beginning

|   | (12)特許協力条約に基   | づいて公開された国際出願   |   | Г  |  |  |  |  |
|---|--|--|---|--|--|--|--|--|
|   | (19)世界知的所有権機関<br>国際事務局   |  | Publicat  | ion!   | UK Patent Applie   | catio  | (13) GB (11) 2 342 597 (13) A<br>(43) Date of A Publication 19.04.2000   |  |
| .   | (43) 国際公開日<br>2006 年1 月19 日 (19.01.2006) PC  | T (10) 国際公開番号<br>WO 2006/006414 A1   |   |  | (21) Application No 9921660.8<br>(22) Date of Filing 15.09.1999  |  | (51) INT CL <sup>7</sup><br>F02D 41/02 , F01N 3/28 7/00 9/00   |  |
|   | 51) 国際特許分類 <sup>7</sup> :         C07C 45/28,<br>45/29, 49/453 // C07B 61/00           21) 国際出願書号:         PCT/JP2005/012056   | 1050001 東京都港区虎ノ門三1<br>ストン虎ノ門ビル 6 階 大谷特   | Europäisches Patentamt<br>European Patent Office  |  |  | DE   | (52)         UK CL (Edition R)           BTW WD W18D W6A         650           (56)         Documents Cited           GB 207311 A         EP 0956801 A1         EP 0036349 A2           EP 092895 A2         P 090085500 A         US 577866 A |  |
|   | 22) 国際出版日: 2005年6月30日(30.06.2005)  | BR, BW, BY, BZ, CA, CH, CN, O<br>DM, DZ, FC, FE, FG, FS, FL GB   | Office européen des brevets   | (11)   | EP 1 645 618 A1  | anyl   | US 5771685 A US 5437153 A  |  |
|   | <ol> <li>25) 国際出版の言語: 日本語</li> <li>26) 国際公開の言語: 日本語</li> </ol>   | LR, LS, LT, LU, LV, MA, MD, M  |   | (,   |  | <b>~</b> ¥                                       | (58) Field of Search<br>UK CL (Edition R.) BTW WAX WD WX<br>INT CL <sup>2</sup> B01D 53/54, F01N 3/00 7/00 9/00, F02D<br>41/02   |  |
|   | 30) 優先権データ:  | SC, SD, SE, SG, SK, SL, SM, S<br>TZ, UA, UG, US, UZ, VC, VN, Y   | EUROPÄISCHE PA  |  | NG   |  | 41/02<br>On-line: WPI, EPODOC, PAJ   |  |
|   | 特願2004-200399 2004年7月7日(07.07.2004) JP<br>71) 出職人(米国を除く全ての指定国について):出光果産  | (84) 悟正論(表示のない限り、主 (+3) Ven<br>が可能にAPIPO(PW)CLICM  | iffentlichungstag:<br>4.2006 Patentblatt 2006/15  | (51) Int CL:<br>C11D 1/72 <sup>(2006.0</sup>   | C11D 3/34 <sup>(2006.01)</sup>   |  |  |  |
|   | 株式会社 (DEMITSU KOSAN CO., LTD.) [JP/JP]: 〒<br>1008321 東京都千代田区丸の内三丁目 1番 1号 Tokyo<br>(JP).  | BU, SL, SZ, IZ, UU, ZM, ZW),<br>BY, KG, KZ, MD, RU, TJ, TM)<br>BG, CH, CY, CZ, DE, DK, EE, E (21) Ann      | eldenummer: 05021124.2  |  |  | L1 JAB,  |  |  |
|   | 72) 発明者;および  | IE, IS, IT, LT, LU, MC, NL, PL, F<br>OAPI (BF, BJ, CF, CG, CI, CM,<br>MR, NE, SN, TD, TG). (22) Ann        | eldetag: 28.09.2005   |  |  |  |  |  |
|   | 75) 発明者(出職人) (米国についてのみ): 小鳥明道(KO)<br>JIMA、Aklo) (JP/P): 〒2990193 千葉県市原市訪崎海<br>岸1番地1 Chiba (JP)、山根 秀樹 (YAMANE, Hideki)<br>(JP/JP): 〒2990193 千葉県市原市鎬崎海岸1番地1<br>Chiba (JP): 国本 覧着 (OKAMOTO, Kengi) [JP/P]: 〒  | ⇒ 浄付公開書類:<br>→ 国際調査報告書<br>2文字コード及び他の略語について<br>各PCTガゼットの巻頭に掲載されす<br>▲ 1000000000000000000000000000000000000 | annte Vertragsstaaten:<br>3E BG CH CY CZ DE DK EE ES FI FR GB GR  | (72) Erfinder:<br>• Böhme, Corinna   |  | IO <sub>x</sub> absort                           | i.c.e. degrades during its lifetime. The NO <sub>x</sub> trap is<br>bed) and rich-burn fumes (NO <sub>x</sub> desorbed and   |  |
|   | 2990193 千葉県市原市姉崎海岸 1 番地 1 Chiba (JP).  |  | E IS IT LI LT LU LV MC NL PL PT RO SE SI  | 41539 Dormage  | in (DE)  | lby SO <sub>x</sub> , a<br>≬O <sub>∞</sub> senso | Ind its cells become contaminated, so that it absorbs<br>or downstream of the NO <sub>x</sub> trap the ever-shortening<br>sured, and from this the limited capacity of the NO <sub>x</sub>   |  |
| (54) Title: METHIOD FOR PRODUCING 2-ADAMANTANONE         ●           (54) 免明の名称: 2 - アダマンタノンの製造方法         110 |  |  |   |  |  |  | ging periods, or for NO <sub>x</sub> mass flow, can be<br>trap was new, and thereby indicate if the device is  |  |
|   | 57) Abstract: Diveloved is a method for producing 2-adam<br>i-adamataned wherein suffaric acid in combination with a can<br>be subcrively adamataneous can be selectively and efficien<br>nethods by oxidizing adamatane or 1-adamantanol.<br>57) 要称: 本発明は、アダマンタンおよび1-アダマ<br>ダインターンク学調査する方法において、創たれた | recover and above a sumonic a sumonic and produced in shorter time with (12) Pate Cao e                    | Siving at least of<br>door as subtrive time with<br>Sandart 3 door as subtrive time with<br>Sandart 3 door as subtrive time with<br>Cao et al.<br>(19) United States<br>(19) Patent Application Publication (10) Pub. No.: US 2006/0074267 A1<br>Cao et al.<br>(10) Pub. Date: Apr. 6, 2006 |  |  |  |  |  |
|   | アダマンタノンを製造する方法において、飯化剤とし<br>片存させた酸化剤を用いる2-アダマンタノンの製造方<br>して、従来になく短時間、かつ高収率で2-アダマン  | 5法であり、アダマンタンや<br>/タノンを選択的に効率よく<br>(54) ALUM  | INOPHOSPHATE MOLECULAR<br>, ITS SYNTHESIS AND USE   | Related U  | U.S. Application Data  |  | G  |  |
| 4 A1  |  | (76) Invent  | ors: Guang Cao, Branchburg, NJ (US);<br>Matu J. Shah, Hackettstown, NJ (US);  | (60) Provisional appli<br>1, 2004.   | ication No. 60/615,111, filed on Oct.  |  |  |  |
| WO 2006/006414  |  |  | John F. Brody, Bound Brook, NJ (US);<br>Douglas Lewis Dorset, Milford, NJ<br>(US); Karl G. Strohmaier, Port<br>Murray, NJ (US)  | Publics<br>(51) Int. Cl.<br><i>C07C 1/00</i><br><i>C01B 37/04</i><br><i>C01B 37/06</i> | (2006.01)<br>(2006.01)<br>(2006.01)  |  | Fig. 2   |  |
| 0M  |  | EXXC<br>5200 1   | ondence Address:<br>NMOBIL CHEMICAL COMPANY<br>AYWAY DRIVE  | (52) U.S. Cl   |  |  |  |  |
|   |  |  | OX 2149<br>OWN, TX 77522-2149 (US)  |  | ABSTRACT<br>luminophosphate molecular sieve is   |  |  |  |
|   |  | (21) Appl.   | No.: 11/231,677   | disclosed The material<br>including the lines lister                                   | I has an X-ray diffraction pattern<br>d in Table 4 and is synthesized in the<br>aminopyridine as structure directing |  |  |  |
|   |  | (22) Filed:  | Sep. 21, 2005   | agent.   |  |  |  |  |
|   |  |  |   |  |  |  |  |  |
|   |  |  |   |  |  |  |  |  |

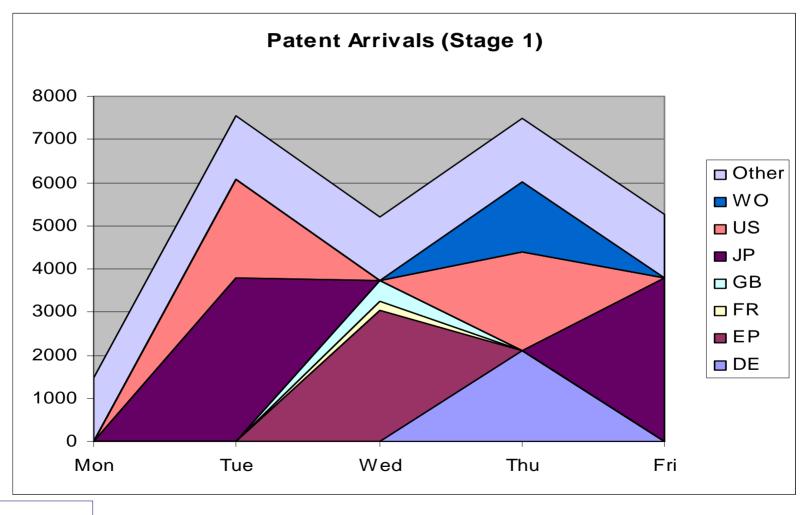


### **DWPI** Preliminary Processing - Data extraction

- Data sources
  - 41 countries; 38K patents per week
- Data formats
  - ASCII text, SGML, XML, Tiff images, PDF
- Delivery medium
  - disk, ftp, email, paper, magnetic tape increasingly electronic
- Data content
  - bibliographic data, abstracts, full patent specifications, Machine Translation (MAT)
- Currently 18 National Languages covered in Patents received
  - e.g. Japanese, French, German, Russian, Italian, Hungarian, Hindi



#### **DWPI** Weekly Patent Volumes – Major Offices



#### **Overview of DWPI Editorial Process**

- Process Bibliographic information
  - Standardisation of company names
  - Data corrections e.g. invalid/missing IPCs
- Create Patent family identify patents that relate to the same invention
  - Basic/Equivalent searches
  - Identify Non-Conventional filings
- Apply Classification
- Create Title/Abstracts
- Apply Manual Coding/Indexing
- Upload completed records to product



## **Preliminary Processing – Data Validation and Correction**

#### • Bibliographic data:

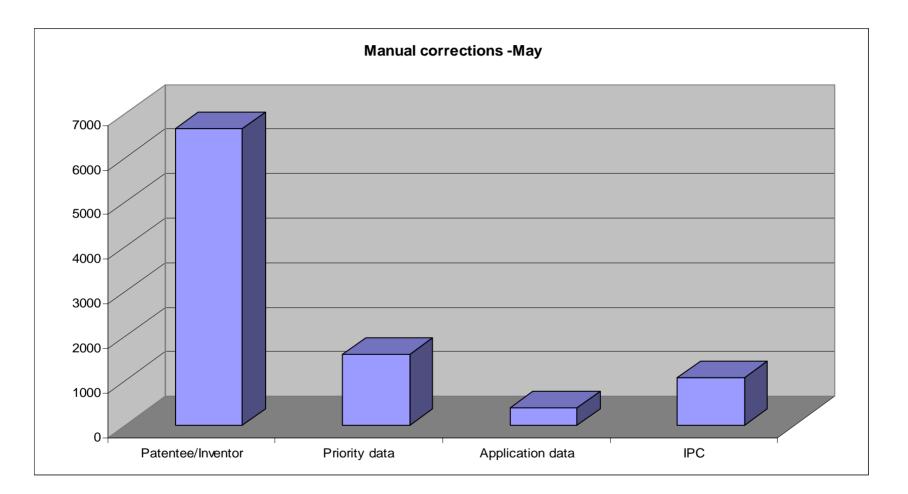
- Patent application numbers and dates
- Priority numbers and dates
- Assignee or applicant (company/individual) details
- Inventor names, addresses
- International Patent Classification (IPC)
- Patent agent details
- Status Designated states (EP/WO)
- Value added intellectually through cleaning of raw patent data during DWPI processing

#### • Error corrections in DWPI:

- Company (patentee)/inventor names:
  - Language transliteration of company/inventor names
  - Misspelled, incorrect formatting of company and inventor names, company codes
  - Accepting new company names
- Priority dates and numbers (corrections and missing data)
- Application dates and numbers
- Invalid or missing International Classification Symbols

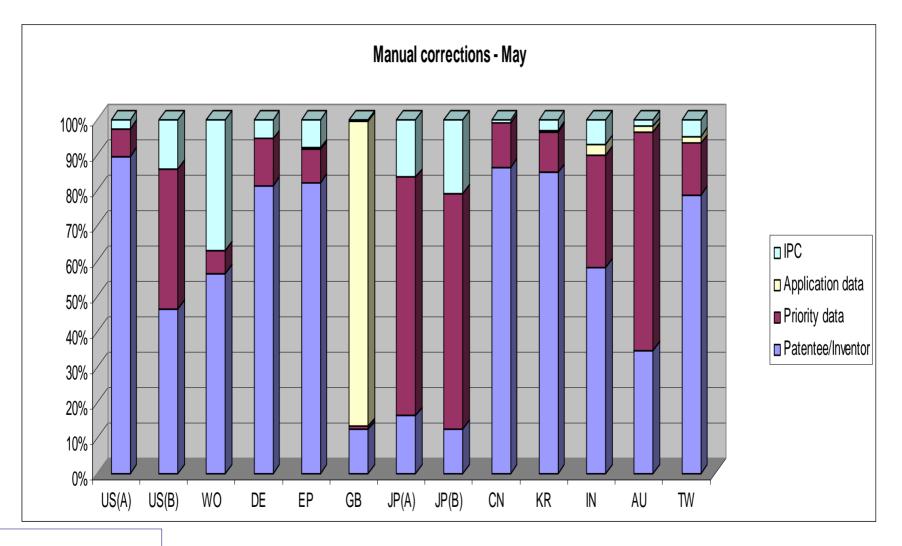


### Number of Manual Error Corrections (DWPI) - May 2007





## Number of Manual Corrections by patent issuing authority (May 2007)



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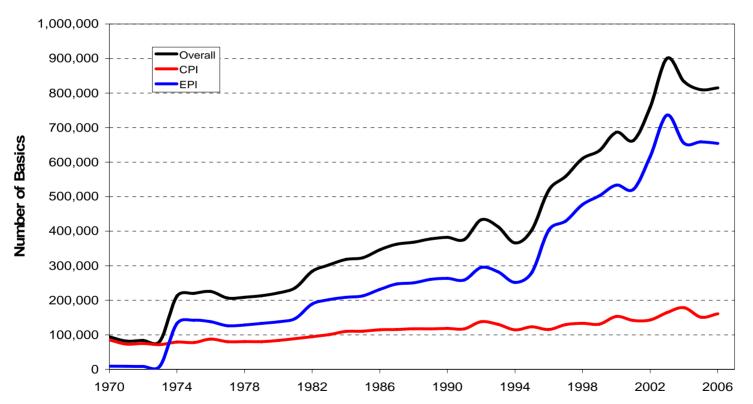
#### **The DWPI Patent Family**

- <u>**DWPI Basic</u>** is defined as the first member of a patent family containing a certain invention which our system received; this may not necessarily be the priority patent filing</u>
- **<u>DWPI Equivalent</u>** is any subsequent family members that is contain the same invention as the basic
- The DWPI basic-equivalent process matches priorities on all incoming applications to priorities existent in the DWPI database
- The algorithm identifies the closely related members of the family through direct priority matches and also indirectly linked family members and creates links between related families
- A team of experts add to the family the non- Convention equivalents that do not have the priority information because were filed after the 12 months period from the priority filing



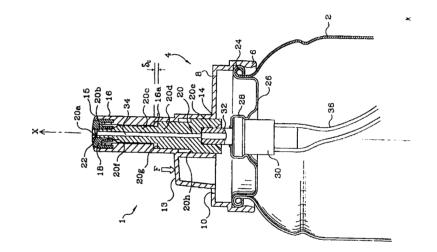
#### **DWPI** Patent Volumes (Basics)

#### **DWPI Basic Volumes**



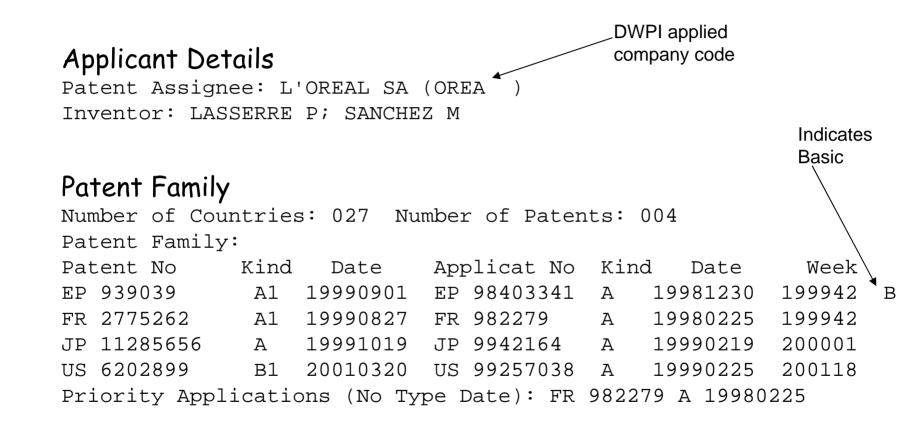
#### **EP0939039 - Our Invention**

- Filed at French Patent Office
  - 25/02/1998
- Filed in European Patent Office
  - 30/12/1998
- Filed at Japanese Patent Office
  - 19/02/1999
- Filed at American Patent Office
  - 25/02/1999





#### EP0939039 - Biblio 1



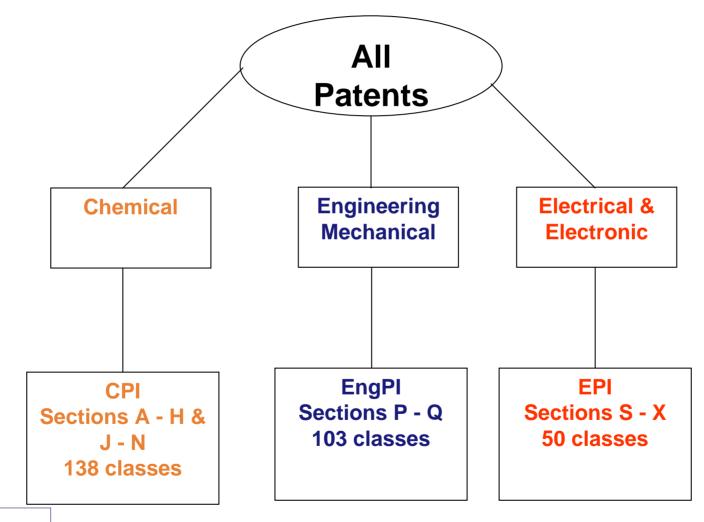


#### EP0939039 - Biblio 2

#### Patent Details: Patent No Kind Lan Pg Main IPC Filing Notes EP 939039 Α1 F 11 B65D-083/16 Designated States (Regional): AL AT BE CH CY DE DK ES FI FR GB GR IE IT LI LT LU LV MC MK NL PT RO SE SI FR 2775262 Δ1 B65D-083/16 **ICIREPAT** Country JP 11285656 A 8 B05B-009/04 Codes US 6202899 B65D-083/00 в1



#### **Classification**





#### **EP0939039 - Classes**

- CPI Interest
  - Claim 7 covers polymer interest
    - must be section A as involves use of specific polymers
      - A8/9 Applications
        - A92 = Packaging & Containers

- EPI Interest
  - None
- EngPl
  - IPC guarantees class
    - B05 = P42
    - B65D-083 = Q34



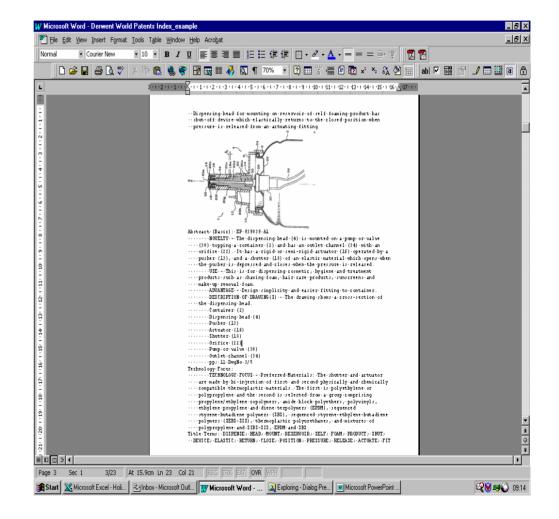
#### **DWPI** Editorial Teams

- Analysts split into teams:
  - Polymers
  - General Chemistry
  - Pharmaceuticals (Chemistry)
  - Pharmaceuticals (Biological)
  - Instrumentation
  - Semiconductors
  - Audio-Visual and Signal Processing
  - Computing
  - Telecommunications
  - Transportation
  - Industrial
  - Power Electronics
- Editorial Hub is based in the UK
- TS Editorial facilities are currently being set up in India
  - Additional resources will enable improvements in quality and timeliness



#### **The Abstract**

- 1. Title
- 2. "Alerting" abstract
- 3. Technology Focus
- 4. Extension abstract





### **The DWPI Title**

- Not the title on the patent
- In English
- Rewritten to cover:
  - Scope = what the invention is
  - Use = what the invention is used for
  - Novelty = what is new about the invention
- Title Terms
  - Autogenerated from title



#### EP0939039 - Title

 Tête de distribution d'un produit et ensemble de distribution sous pression équipé de cette tête

becomes

• Dispensing head for mounting on reservoir of self foaming product has shut-off device which elastically returns to the closed position when pressure is released from an actuating fitting

 Title Terms: DISPENSE; HEAD; MOUNT; RESERVOIR; SELF; FOAM; PRODUCT; SHUT; DEVICE; ELASTIC; RETURN; CLOSE; POSITION; PRESSURE; RELEASE; ACTUATE; FIT



### "Alerting" Abstract

- Up to 7 Fields
  - Novelty
  - Detailed Description
  - Use
  - Advantage
  - Activity
  - Mechanism of Action
  - Description of Drawing(s)





#### EP0939039 - Novelty/Advantage

NOVELTY - The dispensing head (4) is mounted on a pump or valve (30) topping a container (2) and has an outlet channel (34) with an orifice (22). It has a rigid or semi-rigid actuator (16) operated by a pusher (13), and a shutter (18) of an elastic material which opens when the pusher is depressed and closes when the pressure is released.



• ADVANTAGE - Design simplicity and easier fitting to container.



#### EP0939039 - Use/Description of Drawing(s)

- USE This is for dispensing cosmetic, hygiene and treatment products such as shaving foam, hair care products, sunscreens and make-up removal foam.
- DESCRIPTION OF DRAWING(S) The drawing shows a cross-section of the dispensing head.

Container (2)

Dispensing head (4)

Pusher (13)

Actuator (16)

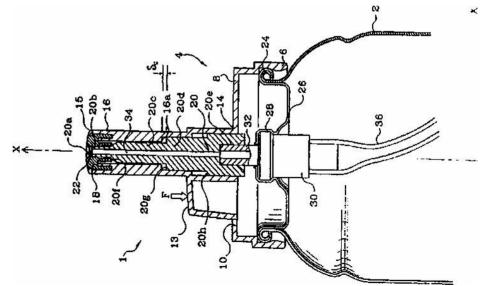
Shutter (18)

Orifice (22)

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Pump or valve (30)

Outlet channel (34)



#### **Technology Focus**

- Technology Specific
  - scientist
- Preferred methods
- Easy to scan headings: agriculture, imaging and communications, biology, pharmaceuticals, polymers textiles and paper, computing and control, etc
  - sub-headings

#### EP0939039 - Technology Focus

TECHNOLOGY FOCUS - POLYMERS - Preferred Materials: The shutter and actuator are made by bi-injection of first and second physically and chemically compatible thermoplastic materials. The first is polyethylene or polypropylene and the second is selected from a group comprising propylene/ethylene copolymers, amide block polyethers, polyvinyls, ethylene propylene and diene terpolymers (EPDM), sequenced styrene-butadiene polymers (SBS), sequenced styrene-ethylene-butadiene polymers (SEBS-SIS), thermoplastic polyurethanes, and mixtures of polypropylene and SIBS-SIS, EPDM and SBS.



#### **The Extension Abstract**

- Wider Disclosure
  - 'inventions' not covered in the claim
- Specific Substances
- Administration
- Example
- Definitions





#### What Does This Look Like?

SPECIFIC COMPOUNDS - 25 Compounds are specifically claimed as (I) for e.g. 5-(2-ethoxy-5-(4-(2-hydroxyethyl)piperazine-1-sulfonyl)phenyl)-1-methyl-3-propyl-1,6-dihydropyrazolo(4,3-d)pyrimidine-7-thione (Ia).

ADMINISTRATION - A composition containing (I) is administered orally, as injection solution (claimed) or parenterally. The dosage is 0.01 - 100 (0.1 - 50) mg/kg.

EXAMPLE - 4-Methoxy-3-(1-methyl-3-propyl-7-thioxo-6,7-dihydro-1Hpyrazolo(4,3-d)pyrimidin-5-yl)-benzenesulfonyl chloride (104.6 mg) was suspended in ethanol (10 ml) and then 1-(2-hydroxyethyl)piperazine (0.10 ml)was added. After the suspension was stirred at room temperature for 12 hours, ethyl acetate (50 ml) and saturated aqueous sodium bicarbonate solution (20 ml) were added. Work-up gave 5-(2-ethoxy-5-(4-(2-hydroxyethyl)piperazine-1-sulfonyl)phenyl)-1methyl-3-propyl-1,6-dihydropyrazolo(4,3-d)pyrimidine-7-thione (Ia) (56.6%) as a yellow solid.



## **DWPI Indexing – Manual Codes**

- Hierarchical, giving more detail as the code gets longer (up to seven levels)
- Intellectually applied, based on the patent content and technology specialist's knowledge of the area of invention
- Highlight novel technical aspects of the invention, as well as applications – taken from e.g. body of the patent specification or the drawings
- Multiple codes applied to a single document to cover all relevant aspects
- Updated yearly by technology specialists based on technology trends and customer feedback

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|     | U11-C04G [1992]   |  |  |  |  |
|-----|---|--|--|--|--|
|     | Ion beam lithography for semiconductor mfr.<br>(H01L-021/027)   |  |  |  |  |
|     | U11-C04G1 [1992]  |  |  |  |  |
|     | Apparatus and method for ion beam<br>lithography<br>(H01J-037/30, H01L-021/027)<br>For control and focusing aspects see also U11-C04A6<br>and U11-C04C2 respectively. See V05-F codes for<br>novel details of apparatus and methods of apparatus<br>monitoring, operation and control   |  |  |  |  |
|     | U11-C04G2 [1992]  |  |  |  |  |
| of  | Masks for ion beam lithography<br>(H01L-021/027, H01J-037/30) (U11-C04A4)<br>Also see V05-F codes for novel ion beam lithography<br>masks.<br><i>stencil mask</i>   |  |  |  |  |
|     | U11-C04H [1992]   |  |  |  |  |
| as  | X-ray lithography for semiconductor mfr.<br>(H01L-021/027)<br><i>Roentgen</i>   |  |  |  |  |
|     | U11-C04H1 [1992]  |  |  |  |  |
| ver | Apparatus and method for X-ray lithography<br>(H01L-021/027, H01J-035) (U11-C04C, U11-C04C1)<br>Includes exposure using X-ray, soft X-ray and<br>ionising ultraviolet radiation (for exposure using<br>non-ionising ultraviolet radiation e.g. DUV see U11-<br>C04E codes). For control and confinement aspects<br>see also U11-C04A6 and U11-C04C2 respectively.<br>See V05-E and V05-F codes for novel details of<br>apparatus and methods of monitoring, operation and<br>control.<br><i>extreme ultraviolet</i> , EUV |  |  |  |  |
| n   | U11-C04H2 [1992]  |  |  |  |  |
|     | X-ray masks<br>(H01L-021/027) (U11-C04A3)<br>Also see V05-E08 codes and V05-F codes for novel<br>X-ray, soft X-ray and EUV lithography masks.   |  |  |  |  |
|     | U11-C04J [2005]   |  |  |  |  |
|     | Imprint lithography for semiconductor mfr.<br>(H01L-021, B41M-003)  |  |  |  |  |

### EP0939039 - Manual Codes

- How are polymers involved?
  - Use of invention = dispensing head for e.g. cosmetic products
  - : Packaging = A12-P

More specific - Closures = A12-P03

Other containers = A12-P06

Bottles, aerosol containers = A12-P06A

- How is packaging formed?
  - Injection moulding = A11-B12
    - To form specific goods A11-B12A



## **DWPI Indexing – Deep Indexing**

- Used to define specific novel features of chemical structures
- Separated into chemical fragments, then translated into chemical codes
- Hierarchical structure allows both specific and generic searching
- Includes formulae and activity coding

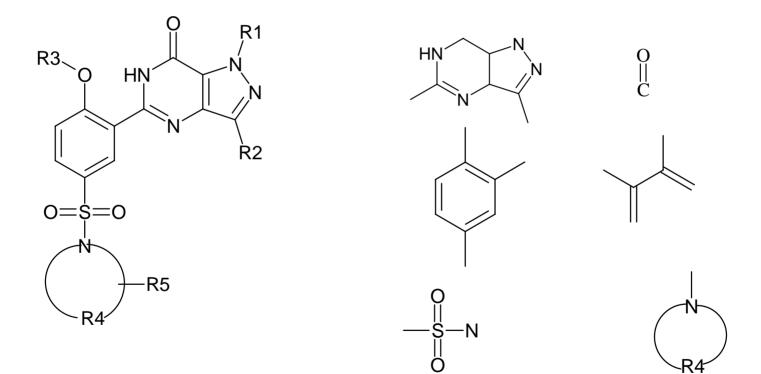
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 Covers all chemical compounds listed in a document

| USE        | Acetone, Formaldehyde<br>resin, other                                | e and Aldehyde/Ket        | one      |
|------------|--|---------------------------|----------|
| ACET       | DNITRILE   | [chemicals]               | R00342   |
| UF         | Methyl cyanide   |                           |          |
| R00        | 342 [8]  |                           |          |
| ٠          | No equivalent AM, KS   | or DR codes               |          |
| ACETO      | OPHENONE   | [chemicals]               | R00675   |
| UF         | Phenyl methyl ketone;  | Acetylbenzene             |          |
| 003<br>067 | [1]<br>6 [5]<br>5 [7]<br>675 [8]                                     |                           |          |
| •          | AM and KS codes repro<br>DR exact corresponden                       |                           | ketone'; |
| ACETO      | XYBENZOIC ACID, 4-   | [polymer <b>f</b> ormers] | R03993   |
| BT         | Monobasic carboxylic a<br>Carboxylic acids<br>Carboxylic derivatives |                           |          |
| 163        | OR (225 (L) 075 (L) (720<br>[3]<br>993 [8]                           | OR 163)》[1]               |          |
| ٠          | AM codes represent 'A<br>'Other aromatic conden                      |                           | ids' or  |

## **Deep Indexing - 1**

### Chemical Indexing: Sections B, C & E





### **Deep Indexing - 1**

### Chemical Indexing: What does it look like?

M2 \*01\* C316 D013 D019 D920 F011 F014 F553 G015 G100 H1 H181 H2 H201 H212 H5 H541 H8 J5 J521 K0 K3 K353 L9 L941 M1 M113 M210 M211 M212 M213 M231 M240 M272 M273 M281 M282 M320 M412 M431 M511 M521 M531 M540 M782 M904 M905 P520 R023 R031 R038 RIN: 01168 DCN: RA05WZ-K, RA05WZ-T, RA05WZ-M

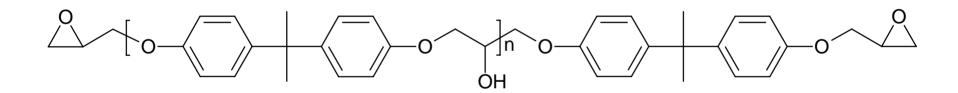
M2 \*02\* D011 D014 D022 D030 D140 E330 H2 H211 J5 J522 L9 L941 L999 M1 M115 M210 M211 M273 M281 M320 M412 M431 M512 M520 M530 M540 M782 M904 M905 P520 R023 R031 R038 RIN: 40336 DCN: RA2HIY-K, RA2HIY-T, RA2-HIY-M

M2 \*03\* D011 D023 E310 H1 H181 H2 H201 H4 H402 H442 H8 M210 M211 M273 M281 M320 M412 M431 M511 M520 M530 M540 M782 M904 M905 M910 P520 R023 R031 R038 RIN: 05171 05171 DCN: R00151-K, R00151-K, R00151-T, R00151-M, R10188-K, R10188-K, R10188-T, R10188-M



## **Deep Indexing - 2**

### **Enhanced Polymer Indexing - Section A**





## **DWPI – Building a Record**

#### JP2003297276

#### Title:

Sample holder cooling device for transmission electron microscope, includes heat insulation unit provided between inner and outer portions of protrusion of sample holder.

#### Patent Assignee:

JEOL Co Ltd

#### IPC:

Main: H01J037-20 Secondary: G01N001-28

#### Novelty:

A sample holder (H) holds a sample at an inner portion (32) of a protrusion (Ha). The coolant tanks (18, 19) respectively cool the outer-side portion (33) and inner portion of the protrusion. The heat conduction elements (23, 24, 26-28, 34), respectively connect the inner portion with the inner tank (19), and the outer portion with the outer tank (18). A heat insulation unit (37) is provided between the inner and outer portions.

#### Use:

For cooling the tip of the sample holder of charged particle-beam apparatus such as transmission electron microscope (TEM).

#### Advantage:

By providing heat insulation unit between the inner and outer portions of the protrusion, the conduction of the heat from the inner portion to the outer portion is prevented. The sample is more efficiently cooled.

#### Description of Drawing(s):

The figure shows a schematic view of the sample holder cooling device.

Coolant tanks 18, 19 Heat conduction elements 23, 24, 26-28,34 Inner portion 32 Outer-side portion 33 Heat insulation unit 37 Sample holder H Protrusion Ha Derwent Class: S03; V05 Manual Codes: S03-E06B1; S03-E06C; V05-F01A1A; V05-F01B3; V05-F04G; V05-F04K

| (19)日本国称     | 桥許庁(JP) | (12) | 公開 | !特 | 許 | 公報   | (A)     | (11)特許出願公開發号<br>特開2003-297276<br>(P2003-297276A) |
|--------------|---------|------|----|----|---|------|---------|--|
|              |         |      |    |    |   |      | (43)公開日 | 平成15年10月17日(2003.10.17)                          |
| (51) Int.CL? |         | 識別記号 |    |    |   | FI   |         | ラーマユード(参考)                                       |
| H01J         | 37/20   |      |    |    |   | H01J | 37/20   | E 2G052  |
| G 0 1 N      | 1/28    |      |    |    |   | G01N | 1/28    | K 5C001  |

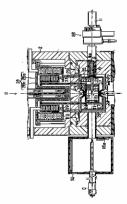
#### 著空詞求 未請求 請求頃の数2 OL (全 9 頁)

-

| (21)出願番号 | <b>坊職2002-102696(</b> P2002-102696) | (71)出職人 000004271                       |
|----------|-------------------------------------|---|
|          |                                     | 日本電子株式会社                                |
| (22)出験日  | 平成14年4月4日(2002.4.4)                 | 東京都昭島市武蔵野 3 丁目 1 番 2 号                  |
|          |                                     | (72) 発明者 守谷 幸二                          |
|          |                                     | 東京都昭島市武蔵野三丁目1番2号 日本                     |
|          |                                     | 電子核式会社内                                 |
|          |                                     | (74)代理人 100094905                       |
|          |                                     | 介理: 田中 隆秀                               |
|          |                                     | Fターム(参考) 20052 DA22 DA24 DA33 UB13 GA33 |
|          |                                     | HAL7 JA04 JA07                          |
|          |                                     | 50001 A401 BR02 0004                    |

#### (54)【発明の名称】 ホルダ先端部冷却装置

#### (57)【嬰約】 【課題】試料ホルダの内方突出部の内側部分を冷却する ための内側冷媒タンクおよび外側部分を冷却するための 外側冷媒タンクを用いて試料ホルダ先端部を極低温に冷 却できるようにすること。 【解決手段】試料ホルダの内方突出部日8の内側部分3 2を冷却するための内側冷媒タンク19および外側部分 33を冷却するための外側冷媒タンク18、試料ホルダ 日の内方突出部日aと内側冷媒タンク19とを接続し且 つ前記内側冷媒タンク19内の冷媒の冷熱を前記試料ホ ルダ日に伝導する内側ホルダ冷却熱伝導部材24、2 8、34、試料ホルダ目の前記内側ホルダ冷却熱伝導部 材24、28、34が接続された部分よりも外端側部分 と前記外側冷媒タンク18とを接続し且つ前記外側冷媒 タンク18内の冷嫌の冷熱を前記試料ホルダ目に伝導す る外側ホルダ冷却熱伝導部村23、27、36とからな るホルダ先端部冷却装置

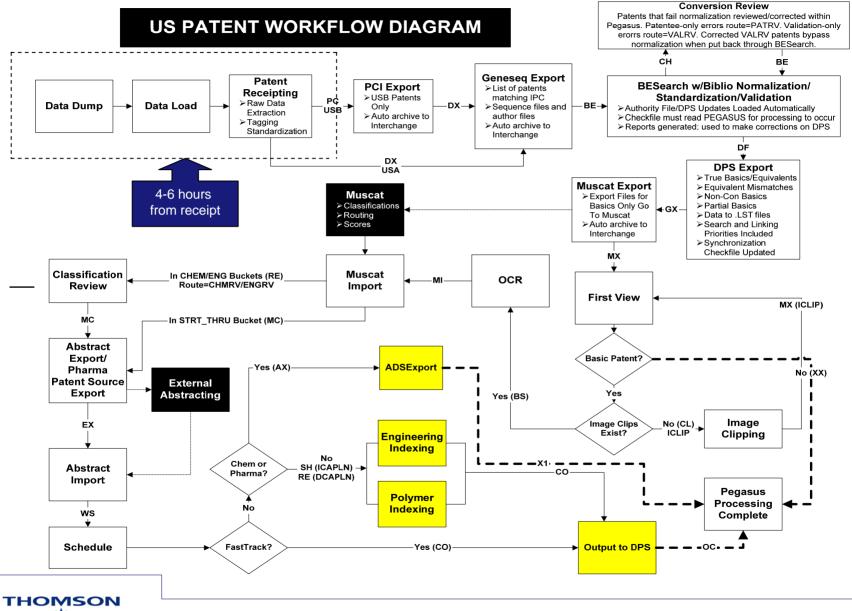


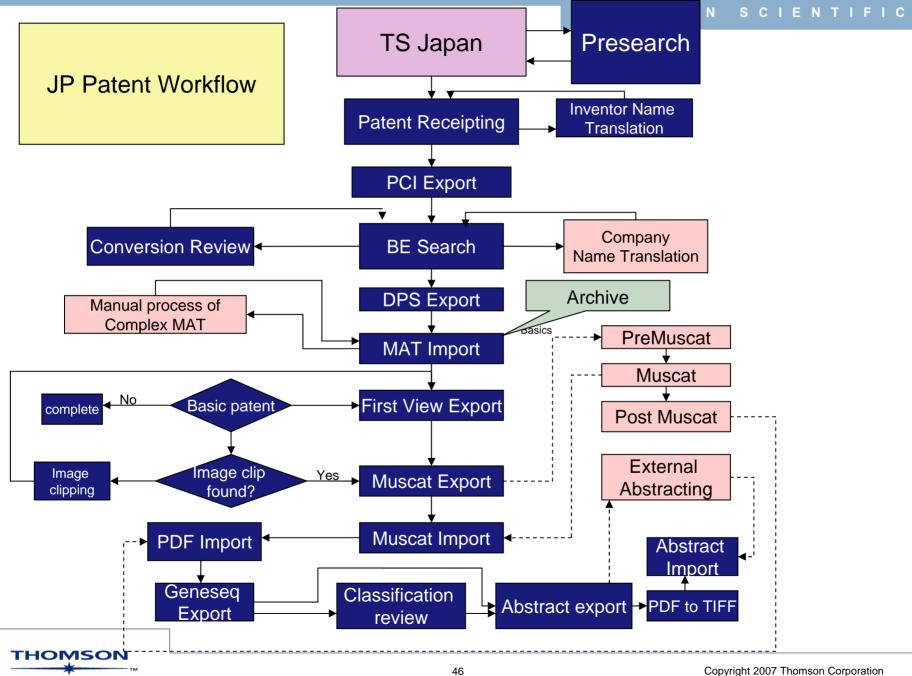


### DWPI – technical system

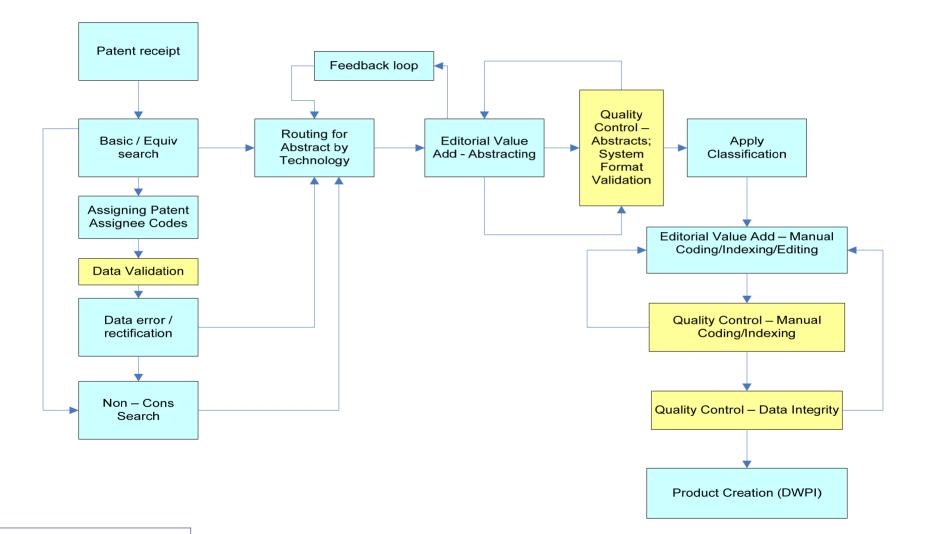
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## **DWPI** Editorial Workflow – Quality Checkpoints



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# Thank you

Q&A

